



Re: Invitation to Recommend Applicants for the Master Program on Intellectual Property Law by Chinese Government Scholarship

To whom it may concern,

On behalf of the National Intellectual Property Administration, PRC (CNIPA), we would like to extend our greetings to you.

We are pleased to inform you that CNIPA, in collaboration with the China Scholarship Council (CSC), will continue to hold the Master Program on Intellectual Property Law (MIPL) sponsored by Chinese Government Scholarship in 2019. This program, as an important move to implement the *Joint Statement on Pragmatic Cooperation in the Field of Intellectual Property among Countries along the "Belt and Road"* in the Field of Intellectual Property, will help nurturing professionals and experts in IP law and administration for the relevant countries.

This program accepts those applications nominated, rather than personal ones, by national IP offices/authorities. Each IP office/authority is invited to recommend 3-4 applicants and send the required application materials as indicated in the Annexes to CNIPA. The applicants may either be officials employed by the national IP offices/authorities or IP practitioners from industries, law firm, etc., in the invited country. After the application is closed, CNIPA will set up an admission panel with the collaborative universities to evaluate the materials and decide the admission of the applicants from each recommending IP office/authority (Please refer to Annex 1 for detailed explanation on the evaluation and admission procedures). Unsuccessful applicants may still be eligible for MIPL the next year.

After being admitted, the candidates will participate in a two-year master program in one of two China's prestigious universities: **Zhongnan University of Economics and Law** and **Tongji University**. The program includes one year of academic study in China and one year in the candidate's country for completing the thesis and oral defense (via video conference) while working.

The admitted applicants will receive the CSC scholarship, which will cover the tuition, accommodation, monthly subsistence allowance, general medical insurance for the candidates for the first year. Please be noted that international flight tickets are not included.

In connection with the above, we cordially invite your organization to nominate 3-4 applicants for the master program in accordance with the abovementioned requirements. We are sending you herewith the General Introduction to the Master Program on Intellectual Property Law (2019) (see Annex 1) and the Application Form for the Master Program on Intellectual Property Law (see Annex 2) and other required materials (Annex 3, 4, and 5). You are requested to send the materials via courier and email to the International Cooperation Department of the China National Intellectual Property Administration, PRC **NO LATER THAN 15 February 2019** (Address: No. 6 Xitucheng Lu, Haidian District, Beijing 100088, People's Republic of China, Attn: Ms. Yao Qingqing, Tel: +86 10 6208 6884, Email: yaoqingqing@sipo.gov.cn).

Should you need any further clarification, please do not hesitate to contact us.

Yours sincerely,



Dr. He Zhimin
Deputy Commissioner